

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

e application of

demitsu AOKI et al.

Serial No. 09/715,000

GROUP 2811

Filed November 20, 2000

Examiner L. Thai

IMPROVED SEMICONDUCTOR WAFER SURFACE AND METHOD OF TREATING A SEMICONDUCTOR WAFER SURFACE

## AMENDMENT

Commissioner for Patents

Sir:

Mashington, D.C. 20231

Responsive to the Official Action of October 17, 2001, please amend the above-identified application as follows:

## IN THE CLAIMS:

Cancel claims 34-56.

## REMARKS

Responsive to the requirement for restriction, Applicant elects Group I, claims 1-33 drawn to the method, without traverse.

Non-elected claims 34-56 are cancelled herewith.

An action on the merits of the elected claims is respectfully requested.

Respectfully submitted,

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November 8, 2001